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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
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10/501,718

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Patrick Chollet

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SUGHRUE MION, PLLC
2100 PENNSYLVANIA AVENUE, N.W.
SUITE 800
WASHINGTON, DC 20037

EXAMINER

ALEJANDRO MULERO, LUZ L

ART UNIT

PAPER NUMBER

1792

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PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Office Action Summary	Application No. 10/501,718	Applicant(s) CHOLLET, PATRICK	
	Examiner Luz L. Alejandro	Art Unit 1792	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- 1) ☒ Responsive to communication(s) filed on 31 July 2008.
- 2a) ☒ This action is **FINAL**. 2b) ☐ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- 4) ☒ Claim(s) 1-20 is/are pending in the application.
- 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
- 5) ☐ Claim(s) _____ is/are allowed.
- 6) ☒ Claim(s) 1-20 is/are rejected.
- 7) ☐ Claim(s) _____ is/are objected to.
- 8) ☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☐ The drawing(s) filed on _____ is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- 12) ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☐ All b) ☐ Some * c) ☐ None of:
1. ☐ Certified copies of the priority documents have been received.
 2. ☐ Certified copies of the priority documents have been received in Application No. _____.
 3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- | | |
|--|---|
| 1) <input type="checkbox"/> Notice of References Cited (PTO-892) | 4) <input type="checkbox"/> Interview Summary (PTO-413) |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948) | Paper No(s)/Mail Date. _____ |
| 3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO/SB/08) | 5) <input type="checkbox"/> Notice of Informal Patent Application |
| Paper No(s)/Mail Date _____ | 6) <input type="checkbox"/> Other: _____ |

DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

Claims 1-13, 15-17, and 19-20 are rejected under 35 U.S.C. 103(a) as being unpatentable over Lieber, DE 4315349 in view of Ota et al., U.S. Patent 5,074,245.

Lieber shows the invention substantially as claimed including a device for processing the surface of a container 10, in which the processing is accomplished by a low-pressure plasma, by excitation of a reaction fluid with microwave electromagnetic waves, the device for processing comprising: an enclosure 6 in which the container is placed, the enclosure being made of a conductive material, inside of the enclosure, the microwaves are introduced by a coupling device; a tube 2 which surrounds the container to delimit an internal cavity of the enclosure, such that an open space is provided between the enclosure and the tube; a device 14 extending into the enclosure to hold the neck of the container; wherein the enclosure is a cylinder and its central axis is a main axis of the container, such that the microwave coupling device is disposed outside the tube and extends towards the main axis of the enclosure and which is provided within a window of a wall of the enclosure, said tunnel projected on a plane tangent to the enclosure, and wherein the inside diameter of the enclosure is such that

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the microwaves are propagated into the open space between the enclosure and the tube, before reaching the tube, primarily according to a mode in which an electrical field, resulting from a propagation of the microwaves, has an axial symmetry with respect to the central axis of the enclosure, the device for processing further comprising a first ring-shaped plate 3 and a second ring-shaped plate 4 provided inside the enclosure and formed so as to surround the tube; wherein the first ring-shaped plate is axially offset from the second ring-shaped plate so that the first ring-shaped plate is provided above the window of the wall of the enclosure and the second ring-shaped plate is provided below the window of the wall of the enclosure (see, for example, abstract and fig. 1, and the machine translation of the whole document).

Lieber does not expressly disclose that the microwave coupling device comprises a waveguide tunnel and is rectangular in shape, and the smaller dimension of the rectangle corresponds to its dimension along the direction of the axis of the enclosure. Ota et al. discloses a microwave coupling device that includes a waveguide tunnel 8 that is rectangular in shape, and the smaller dimension of the rectangle corresponds to its dimension along the direction of the axis of the enclosure 3 (see fig. 4 and its description). In view of this disclosure, it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the apparatus of Lieber so as to include the waveguide tunnel of Ota et al. because such waveguide structure is used and known to be suitable for effective formation of microwave plasma in order to efficiently process a workpiece in the apparatus.

Lieber and Ota et al. do not expressly disclose the claimed inside diameters of the enclosure and the dimensions of the wave guide tunnel, however, a prima facie case of obviousness still exists because it would have been an obvious choice of design to one having ordinary skill in the art at the time the invention was made to select/optimize the inside diameter of the enclosure and the dimensions of the wave guide tunnel, as claimed depending on the object to be processed and/or the coupling mode required, and such limitation would not lend patentability to the instant application absent the showing of unexpected results. Furthermore, where the only difference between the prior art and the claims was a recitation of relative dimensions of the claimed device and a device having the claimed relative dimensions would not perform differently than the prior art device, the claimed device was not patentably distinct from the prior art device. Also, note that the claimed variations of the intensity of the electrical field will be achieved depending on the dimension of the enclosure, and the wavelength of the microwave.

With respect to the container having an elongated neck portion and claims 10-11 and 13, such limitations are not given patentable weight in apparatus claims because they are directed to the material or article worked upon and therefore do not limit the apparatus claims. Furthermore, note that the apparatus of Lieber modified by Ota et al. is capable of processing a container having an elongated neck portion, that comprises a processed inner and/or outer face(s) and/or a container that comprises a material deposited by low-pressure plasma.

Regarding claim 12, note that inside the enclosure of the apparatus of Lieber, the tube 2 is delimited by a wall made of a material that is transparent to the microwaves.

Concerning claim 15, note that in the apparatus of Lieber modified by Ota et al. the waveguide protrudes past a wall of the enclosure towards the container.

With respect to claim 16, the container is disposed so that its bottom is spaced apart from the enclosure.

Moreover, concerning claims 17 and 19, the waveguide in the apparatus of Lieber modified by Ota et al. is in the form of a rectangle having a uniform rectangular cross section extending to a back wall of the waveguide and the cavity is coaxially disposed with respect to the enclosure.

Regarding claim 20, making an apparatus adjustable is obvious to one of ordinary skill in the art.

Claim 14 is rejected under 35 U.S.C. 103(a) as being unpatentable over Lieber, DE 4315349 in view of Ota et al., U.S. Patent 5,074,245 as applied to claims 1-13, 15-17, and 19-20 above, and further in view of Ohkawa, U.S. Patent 5,225,740.

Lieber and Ota et al. are applied as above but do not expressly disclose the tube is made of quartz. Ohkawa discloses quartz being used as a microwave transmission material (see col. 8-lines 19-23). In view of this disclosure, it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the apparatus of Lieber modified by Ota et al. so as to use quartz as the tube material because such material is used and known to be suitable for transmitting microwaves.

Claim 18 is rejected under 35 U.S.C. 103(a) as being unpatentable over Lieber, DE 4315349 in view of Ota et al., U.S. Patent 5,074,245 as applied to claims 1-13, 15-17, and 19-20 above, and further in view of Tanaka et al., U.S. Patent 4,970,435.

Lieber and Ota et al. are applied as above but do not expressly disclose a generator which produces the electromagnetic waves, and the generator is disposed to protrude into the waveguide tunnel. Tanaka et al. discloses a generator 11 which produces the electromagnetic waves, and the generator is disposed to protrude into the waveguide tunnel (see fig. 1 and its description). In view of this disclosure, it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the apparatus of Lieber modified by Ota et al. so as to comprise the waveguide generator structure of Tanaka et al. because such a structure is used and known to be a suitable, efficient and effective means to generate microwave plasma in a processing chamber.

Response to Arguments

Applicant's arguments filed 07/31/08 have been fully considered but they are not persuasive. Applicant argues the claimed first and second ring-shaped plates are not shown. However, the examiner respectfully contends that the device for processing further comprising a first ring-shaped plate 3 and a second ring-shaped plate 4 provided inside the enclosure and formed so as to surround the tube; wherein the first ring-shaped plate is axially offset from the second ring-shaped plate so that the first ring-

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shaped plate is provided above the window of the wall of the enclosure and the second ring-shaped plate is provided below the window of the wall of the enclosure.

Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Luz L. Alejandro whose telephone number is 571-272-1430. The examiner can normally be reached on Monday to Thursday from 7:30 to 6:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Parviz Hassanzadeh can be reached on 571-272-1435. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Luz L. Alejandro/
Primary Examiner, Art Unit 1792

November 5, 2008